Extracting the electron-induced molecular desorption coefficient using an electron detector

Ubaldo Iriso

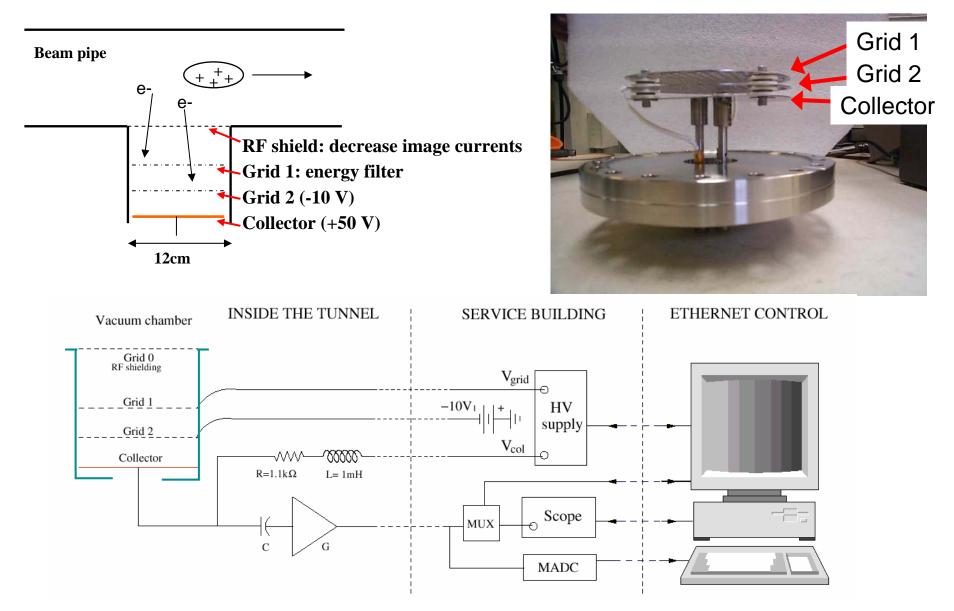
Many thanks to: M. Blaskiewicz, A. Drees, W. Fischer, H. Hseuh, S. Peggs, G. Rumolo, R. Tomás, P. Thieberger, and S.Y. Zhang

Contents

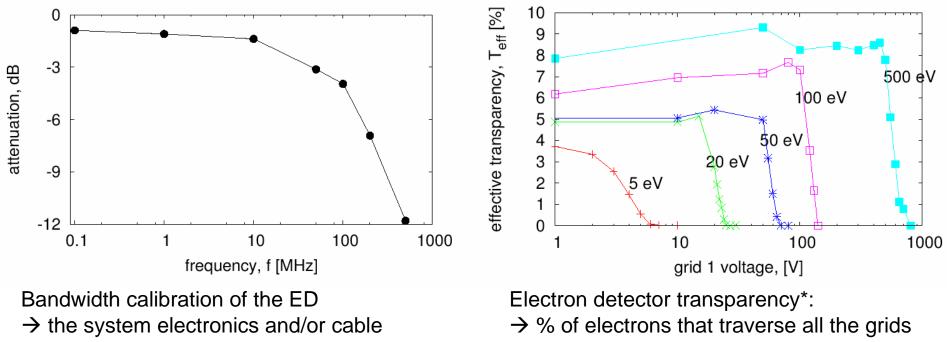
- 1. Introduction
 - a) Calibration of the RHIC e-detector
 - b) Snapshot examples
- 2. Electron-induced molecular desorption
- 3. Evolution of η_{e} for baked and unbaked surfaces
- 4. Electron energy spectrum
- 5. Conclusions

1. Introduction

• Electron detector at RHIC (very similar to APS, SPS, KEK...)



1.a. Calibration of the RHIC e-detector



length does not affect the signal below 50MHz (3 dB limit)

and can reach the collector

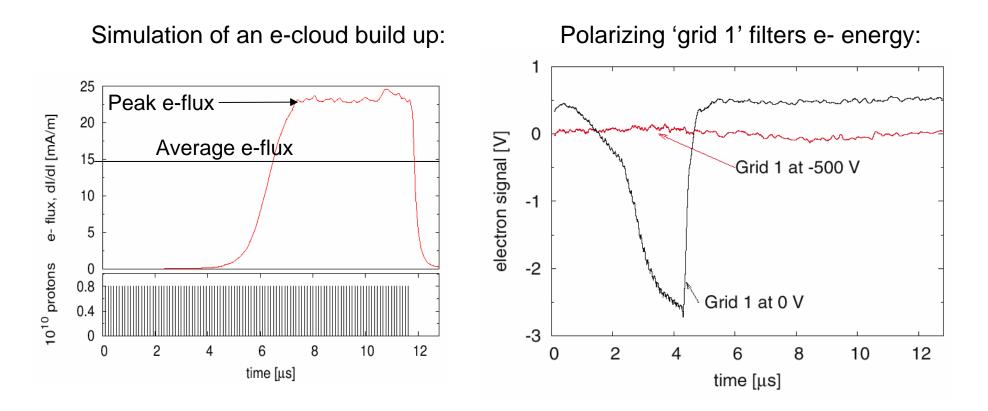
→ These two calibrations provide the e- flux to the wall for a given ED voltage

$$\frac{dI}{dA} = \frac{V}{ZGA_{\rm ED}T_{\rm eff}}$$

Z : line impedance G : amplifier gain A_{ED} : ED surface T_{eff} : effective transparency

See *P. He et al, TPAG004, PAC'03.

1.b. Snapshot examples:



- Distinguish between peak e- signal and average e-signal
- Filter electron energy

2. Electron induced molecular desorption

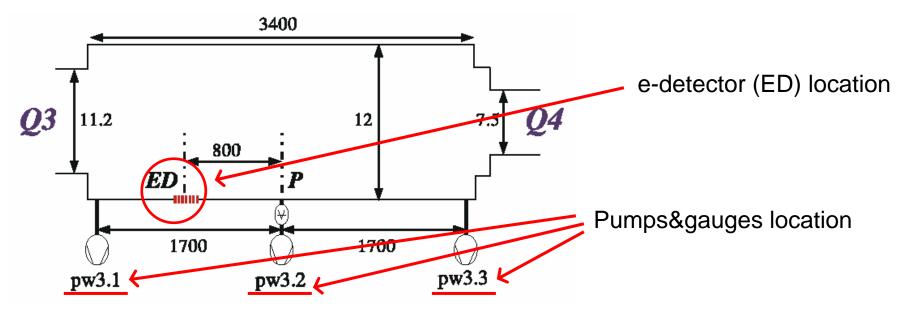
The pressure in presence of an e-cloud*:

$$P(z) = P_0 + \eta_e \frac{kT}{e} \left\langle \frac{dI}{dl} \right\rangle_{\tau} \left[\frac{2Lz - z^2}{2c} + \frac{L}{S} \right]$$

 $\eta_e = \#$ molecules / electron <dI/dI> = linear electron flux to the wall, time averaged over one turn 2S = pumping speed

Assuming a periodic structure (pumps spaced by 2L)
z origin at a vacuum pump location

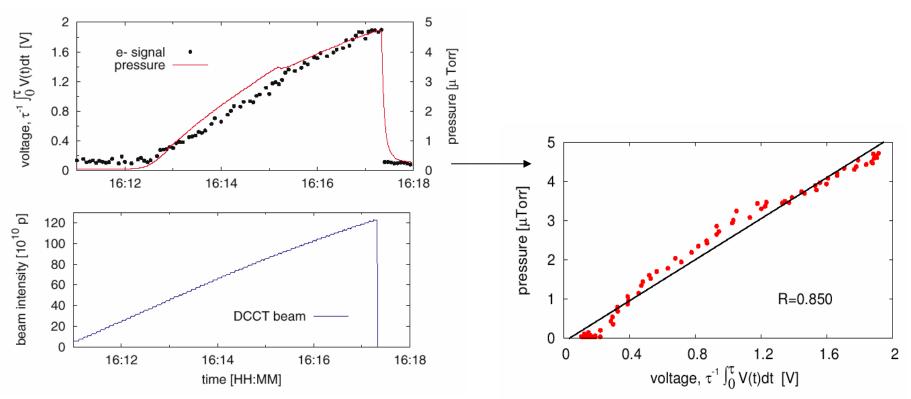
Experimental setup at BO2 in RHIC (unbaked stainless steel):



*See U. Iriso and W. Fischer, PRST-AB, 8, 113201, 2005

2. Electron induced molecular desorption

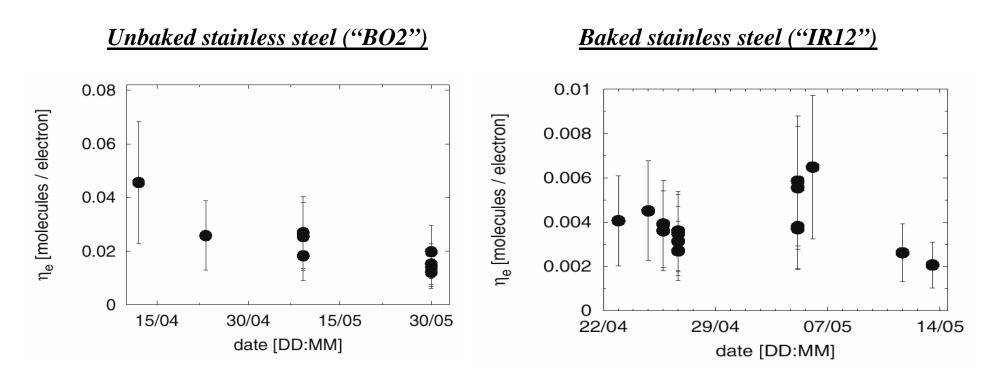
Evolution of the average flux and pressure during electron clouds at BO2



Using a simple linear regression, infer desorption coefficient η_e . In this case, $\eta_e = 0.01 \pm 50\%$. (error stems from the uncertainty in pressure readings and pumping speed values)

<u>3. Evolution of η_e for baked and unbaked</u> <u>stainless steel</u>

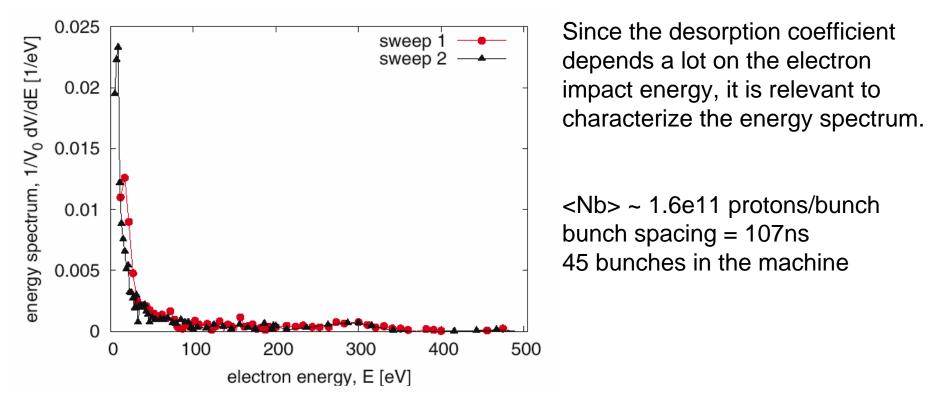
• Following the evolution of $\eta_e \rightarrow$ evaluation of the surface conditioning



•Unbaked stainless steel suffers small conditioning.

•Baked surfaces do not seem to suffer any scrubbing (low energy e-, low flux, or both)

4. Energy spectrum



- Large peak of low energy e- (~10eV)
- Espectrum extends up to ~300eV upper limit cannot be precisely determined because of the high ED noise.

5. Conclusions

- A proper calibration of the ED allows to infer the electron flux into the wall
- Using the pressure and ED readings, the desorption coefficient is inferred for both baked and unbaked surfaces.
- Baked η_e are about an order of magnitude lower than unbaked η_e , and results are consistent with laboratory measurements
- The electron energy spectrum during multipacting extends up to ~300eV (low fraction). The spectrum shows a large peak at low energy (~10eV).